

Acetic Acid, Glacial  
CMOS



Material No.: 9503-03  
Batch No.: 0000014119  
Manufactured Date: 2012/08/20  
Retest Date: 2017/08/19


## Certificate of Analysis

Test	Specification	Result
Assay (CH <sub>3</sub> COOH) (by freezing point)	>= 99.7 %	99.9
Color (APHA)	<= 10	5
Acetic Anhydride ((CH <sub>3</sub> CO) <sub>2</sub> O)	<= 0.01 %	< 0.01
Acetaldehyde	<= 0.05 %	< 0.01
Residue after Evaporation	<= 4 ppm	2
Solubility in H <sub>2</sub> O	Passes Test	PT
Specific Gravity at 20°/20°C	>= 1.048	1.049
Substances Reducing Dichromate	Passes Test	PT
Substances Reducing Permanganate	Passes Test	PT
Chloride (Cl)	<= 0.5 ppm	< 0.5
Phosphate (PO <sub>4</sub> )	<= 0.5 ppm	< 0.3
Sulfate (SO <sub>4</sub> )	<= 0.5 ppm	< 0.3
Trace Impurities - Aluminum (Al)	<= 50.0 ppb	< 5.0
Arsenic and Antimony (as As)	<= 5 ppb	< 5
Trace Impurities - Barium (Ba)	<= 10.0 ppb	< 1.0
Trace Impurities - Beryllium (Be)	<= 10.0 ppb	< 1.0
Trace Impurities - Bismuth (Bi)	<= 50.0 ppb	< 10.0
Trace Impurities - Boron (B)	<= 10.0 ppb	< 5.0
Trace Impurities - Cadmium (Cd)	<= 10.0 ppb	< 1.0
Trace Impurities - Calcium (Ca)	<= 200.0 ppb	1.8
Trace Impurities - Chromium (Cr)	<= 30.0 ppb	< 1.0
Trace Impurities - Cobalt (Co)	<= 10.0 ppb	< 1.0
Trace Impurities - Copper (Cu)	<= 20.0 ppb	1.6
Trace Impurities - Gallium (Ga)	<= 10.0 ppb	< 1.0


Test	Specification	Result
Trace Impurities – Germanium (Ge)	<= 10.0 ppb	< 10.0
Trace Impurities – Gold (Au)	<= 10.0 ppb	< 5.0
Heavy Metals (as Pb)	<= 300 ppb	< 300
Trace Impurities – Iron (Fe)	<= 100.0 ppb	4.4
Trace Impurities – Lead (Pb)	<= 100.0 ppb	< 10.0
Trace Impurities – Lithium (Li)	<= 10.0 ppb	< 1.0
Trace Impurities – Magnesium (Mg)	<= 50.0 ppb	< 1.0
Trace Impurities – Manganese (Mn)	<= 10.0 ppb	< 1.0
Trace Impurities – Molybdenum (Mo)	<= 10.0 ppb	< 5.0
Trace Impurities – Nickel (Ni)	<= 25.0 ppb	< 5.0
Trace Impurities – Niobium (Nb)	<= 10.0 ppb	< 1.0
Trace Impurities – Potassium (K)	<= 100.0 ppb	< 10.0
Trace Impurities – Silicon (Si)	<= 50.0 ppb	< 10.0
Trace Impurities – Silver (Ag)	<= 10.0 ppb	< 1.0
Trace Impurities – Sodium (Na)	<= 100.0 ppb	< 5.0
Trace Impurities – Strontium (Sr)	<= 10.0 ppb	< 1.0
Trace Impurities – Tantalum (Ta)	<= 10.0 ppb	< 5.0
Trace Impurities – Thallium (Tl)	<= 50.0 ppb	< 5.0
Trace Impurities – Tin (Sn)	<= 50.0 ppb	< 10.0
Trace Impurities – Titanium (Ti)	<= 100.0 ppb	< 1.0
Trace Impurities – Vanadium (V)	<= 10.0 ppb	< 1.0
Trace Impurities – Zinc (Zn)	<= 50.0 ppb	< 1.0
Trace Impurities – Zirconium (Zr)	<= 10.0 ppb	< 1.0
Particle Count – 1.0 µm and greater	<= 10 par/ml	< 1

For Microelectronic Use

Storage Conditions: IMPORTANT: Material will freeze if stored below 17 °C (63°F).  
 Country of Origin: US  
 Packaging Site: Paris Mfg Ctr & DC



Phillipsburg, NJ 9001:2008, 14001:2004  
 Paris, KY 9001:2008  
 Mexico City, Mexico 9001:2008  
 Deventer, The Netherlands 9001:2008, 14001:2004, 13485:2003  
 Gliwice, Poland 9001:2008, 17025:2005  
 Selangor, Malaysia 9001:2008  
 Dehradun, India, 9001:2008, 14001:2004, 13485:2003  
 Mumbai, India, 9001:2008, 17025:2005  
 Panoli, India 9001:2008



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